



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q62447

KANNA, SHINICHI, et al.

Appln. No. 09/748,198

Group Art Unit: 1752

Confirmation No.: 5369

Examiner: S. LEE

Filed: December 27, 2000

For: POSITIVE-WORKING RADIATION-SENSITIVE COMPOSITION

EXCESS CLAIM FEE PAYMENT LETTER

Commissioner for Patents
Washington, D.C. 20231

Sir:

An Amendment Under 37 C.F.R. § 1.111 is attached hereto for concurrent filing in the above-identified application. The resulting excess claim fee has been calculated as shown below:

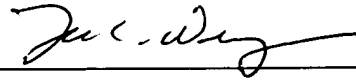
	After Amendment		Highest No. Previously Paid For					
All Claims	<u>21</u>	-	<u>20</u>	=	<u>1</u>	X	<u>\$18.00</u>	= <u>\$18.00</u>
Independent	<u>1</u>	-	<u>3</u>	=		X	<u>\$84.00</u>	= <u>\$0.00</u>
TOTAL								= <u>\$18.00</u>

RECEIVED
JUL 08 2002
TC 1700

Excess Claims Fee Payment Letter
U.S. Appln. No. 09/748,198

A check for the statutory fee of \$18.00 is attached. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account. A duplicate copy of this letter is enclosed.

Respectfully submitted,



Lee C. Wright
Registration No. 41,441

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Date: June 27, 2002



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AMENDMENT UNDER 37 C.F.R. §1.111

Commissioner for Patents
Washington, D.C. 20231

Sir:

This Amendment is submitted in response to the Office Action dated February 27, 2002. A Petition for a one month extension of time is being concurrently filed, making a response due on or before June 27, 2002. Please amend the above-identified application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

1 (amended). A positive-working radiation-sensitive composition comprising
(a) a resin having an acid-decomposing group represented by the following
formula (I), which is decomposed by the action of an acid to increase the solubility in
an alkali developer,

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